CLAIMS

semiconductor substrate, for а ceramic producing/examining device, having a conductor formed inside thereof or on the surface thereof,

wherein said ceramic substrate has been sintered such that a fractured section thereof exhibits intergranular fracture.

- semiconductor substrate for ceramic 2. producing/examining device according to claim 1, 10 wherein an average diameter of ceramic grains of said fractured section is 0.5 to 10 $\mu\,\mathrm{m}$.
- semiconductor for а ceramic substrate 3. The producing/examining device according to claim 1, 15 wherein an impurity element is locally distributed in boundaries of ceramic grains of said fractured section.
- semiconductor for ceramic substrate The 4. producing/examining device according to claim 1, 20 wherein thermal conductivity of said ceramic substrate is 100 W/m·K or more.
- ceramic substrate 5. producing/examining device according to claim 1, 25 wherein said ceramic substrate is constituted such that: an impurity-existent area where an impurity element is locally distributed in triple points of crystal grains, and an impurity element-nonexistent area where an impurity is not locally distributed in the triple points of the crystal 30 grains,

for

semiconductor

coexist therein.